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PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicants : Salvatore Leonardi et al.
Application No. : 10/729,721
Filed : December 5, 2003
For : RESISTIVE STRUCTURE INTEGRATED IN A
SEMICONDUCTOR SUBSTRATE

Examiner : Junghwa M. Im
Art Unit : 2811
Docket No. : 856063.672D1
Date : September 23, 2005

Mail Stop Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

AMENDMENT

Commissioner for Patents:

In response to the Office Action dated March 25, 2005, please extend the period of time for response three months, to expire on September 25, 2005. Enclosed are a Petition for an Extension of Time and the requisite fee. Please amend the application as follows:

Amendments to the Claims are reflected in the listing of claims which begins on page 2 of this paper.

Remarks/Arguments begin on page 6 of this paper.